

Quantum Cascade Detector at 5 micrometers

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Thales Research and Technology

Presentation of the device

- Principle of a QCD
- Description of the sample

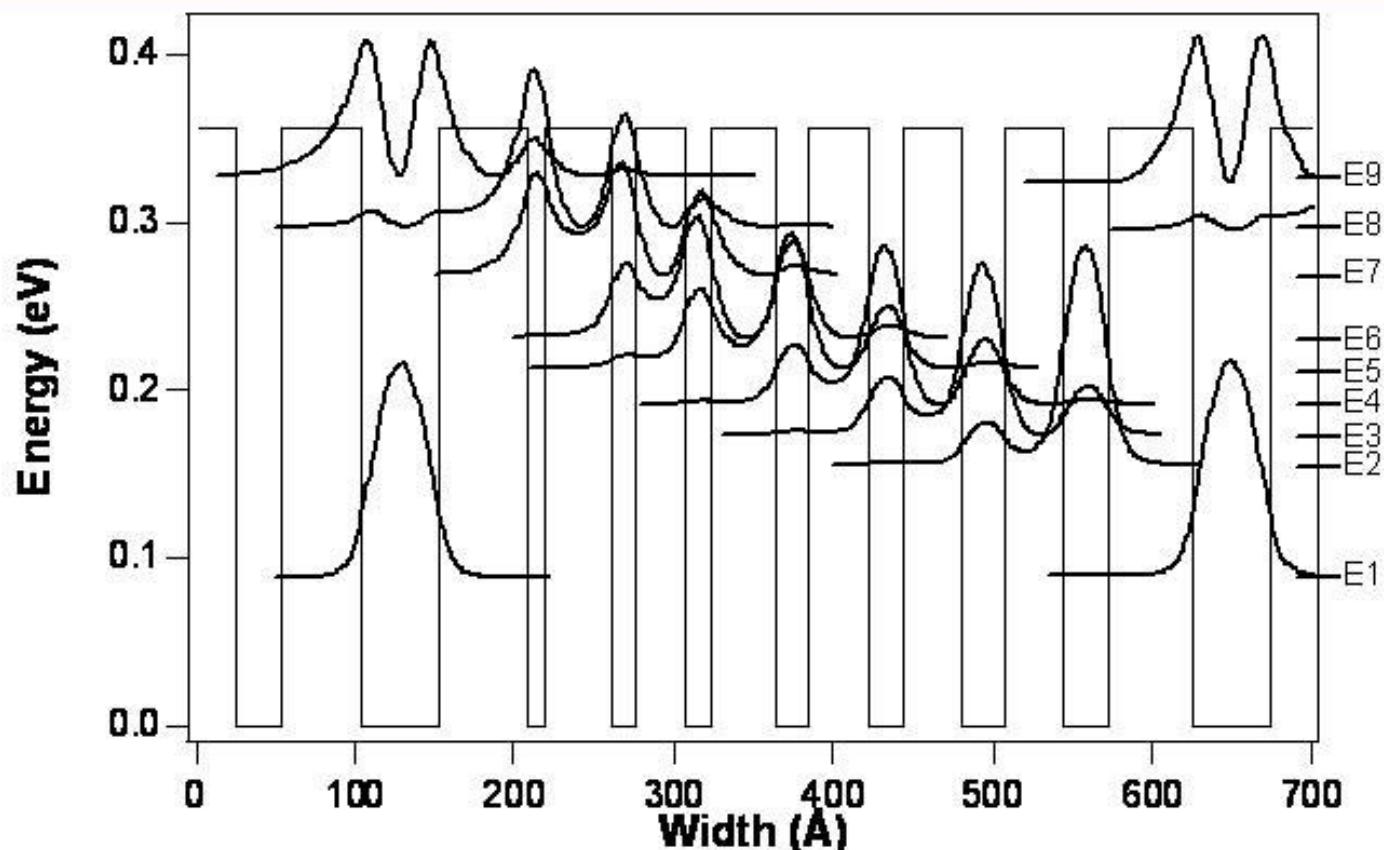
Characterization of the QCD

- Absorption and responsivity spectra
- Resistivity
- Noise and detectivity

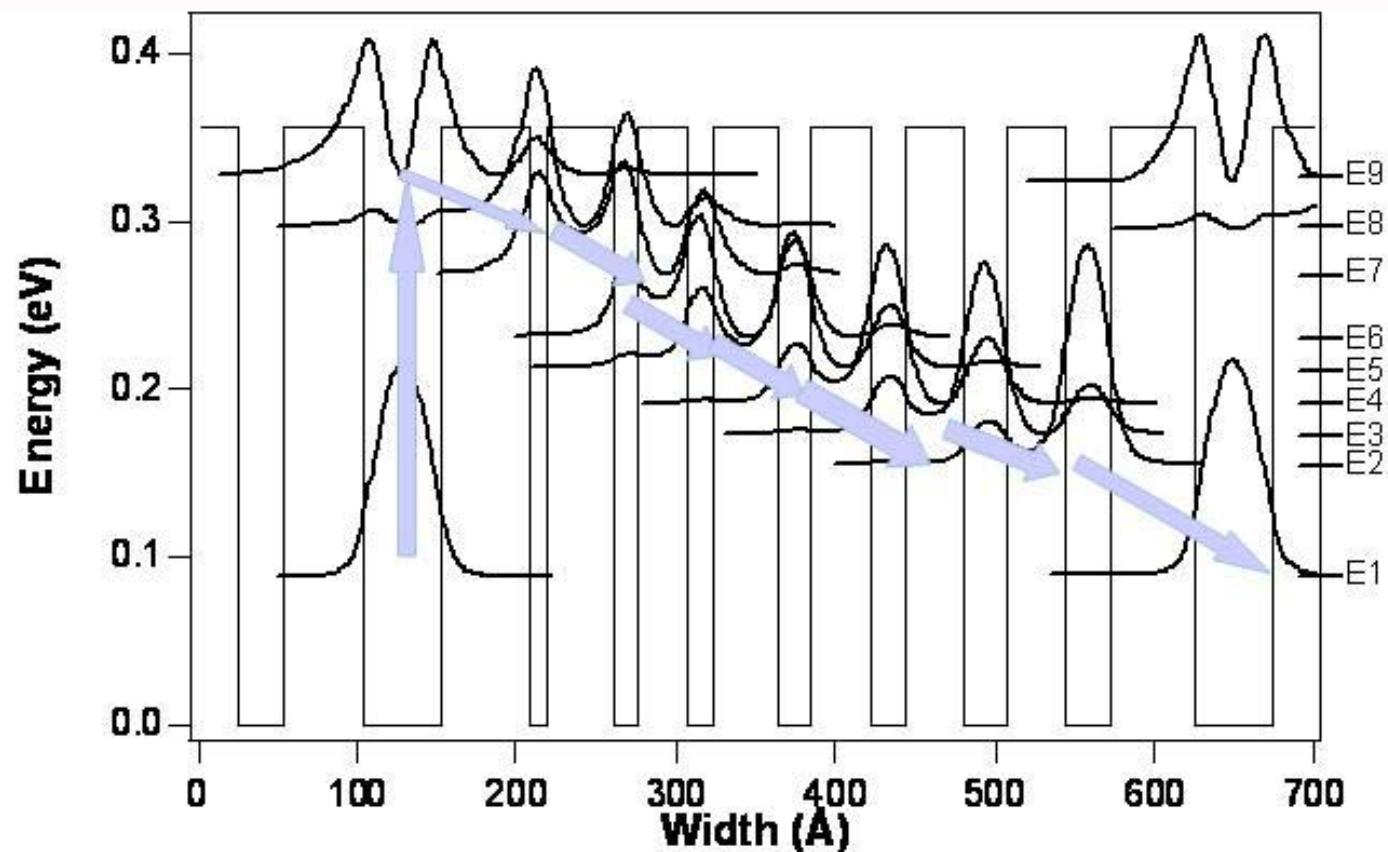
Modeling of electronic transport

- Presentation of the model
- Some results and discussion
- QCD vs QWIP





- 40 periods of 8 barriers and quantum wells
- Quantum Wells : GaAs, thickness between 11 and 30 Å
- Barriers : AlGaAs, 44% Al, thickness between 30 and 60 Å
- 1st Quantum Well Si n-doped : $N_d = 5 \cdot 10^{11} \text{ cm}^{-2}$



- Thales patent “DéTECTEURS à cascade quantiques” (2001)
- Many QCDs have been demonstrated at Neuchatel (2.5 µm, 5.3 µm, 9 µm, 16.5 µm, 84 µm) and Paris (8 µm and 5.7 µm)



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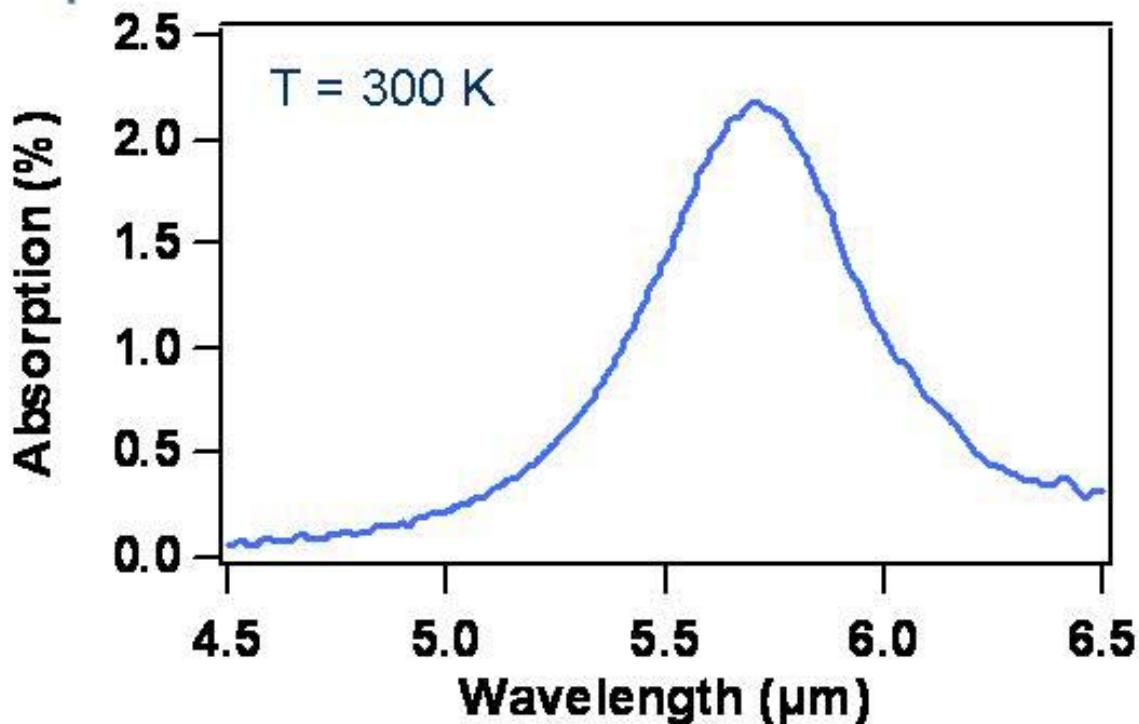
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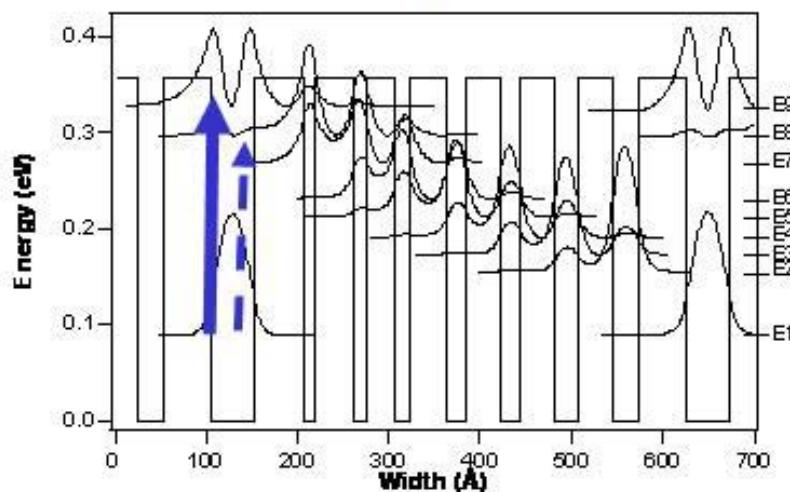
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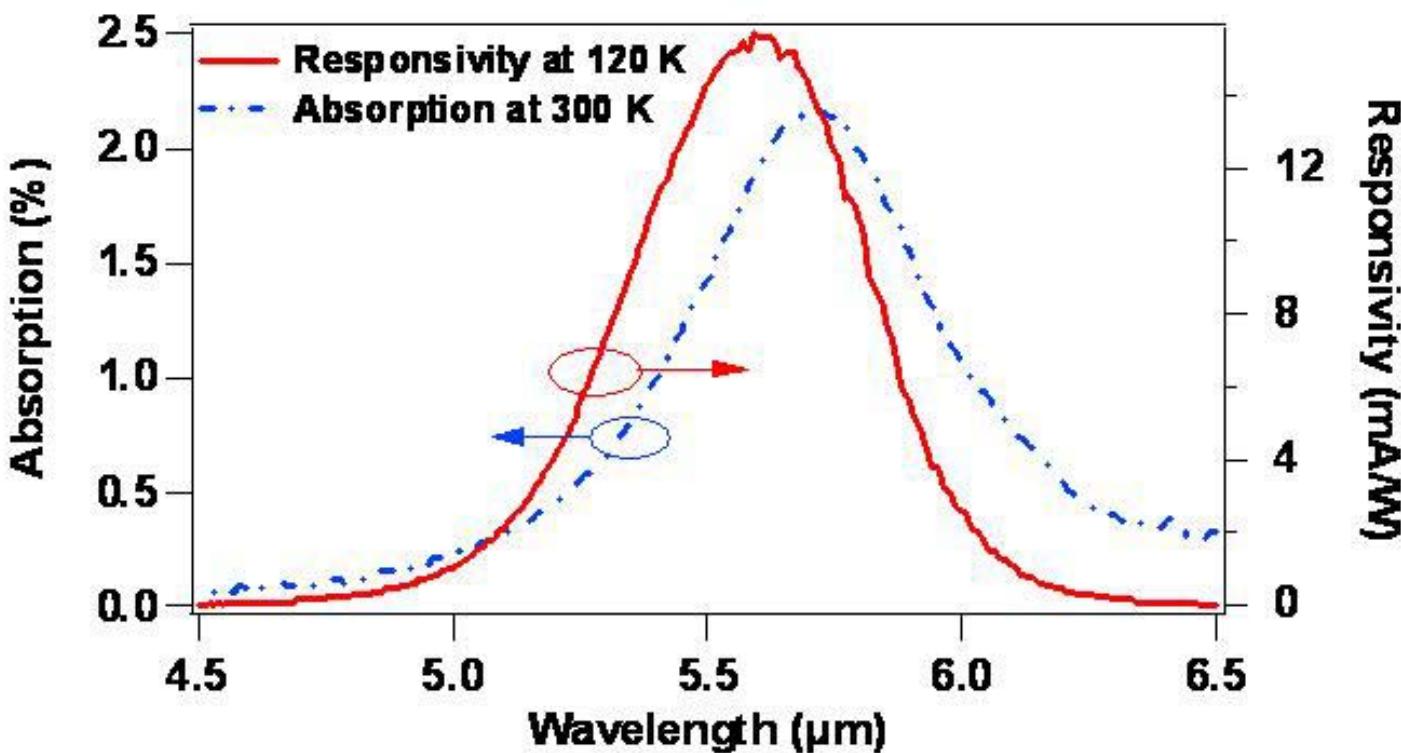
Absorption peak :
 $\lambda = 5.7 \mu\text{m}$



- Multipath absorption measurement on a full wafer
- Doping concentration deduced from absorption coefficient :
 $N_d = 10^{12} \text{ cm}^{-2}$
- % Al deduced from DDX measurement : 47 %



Characterization : Responsivity

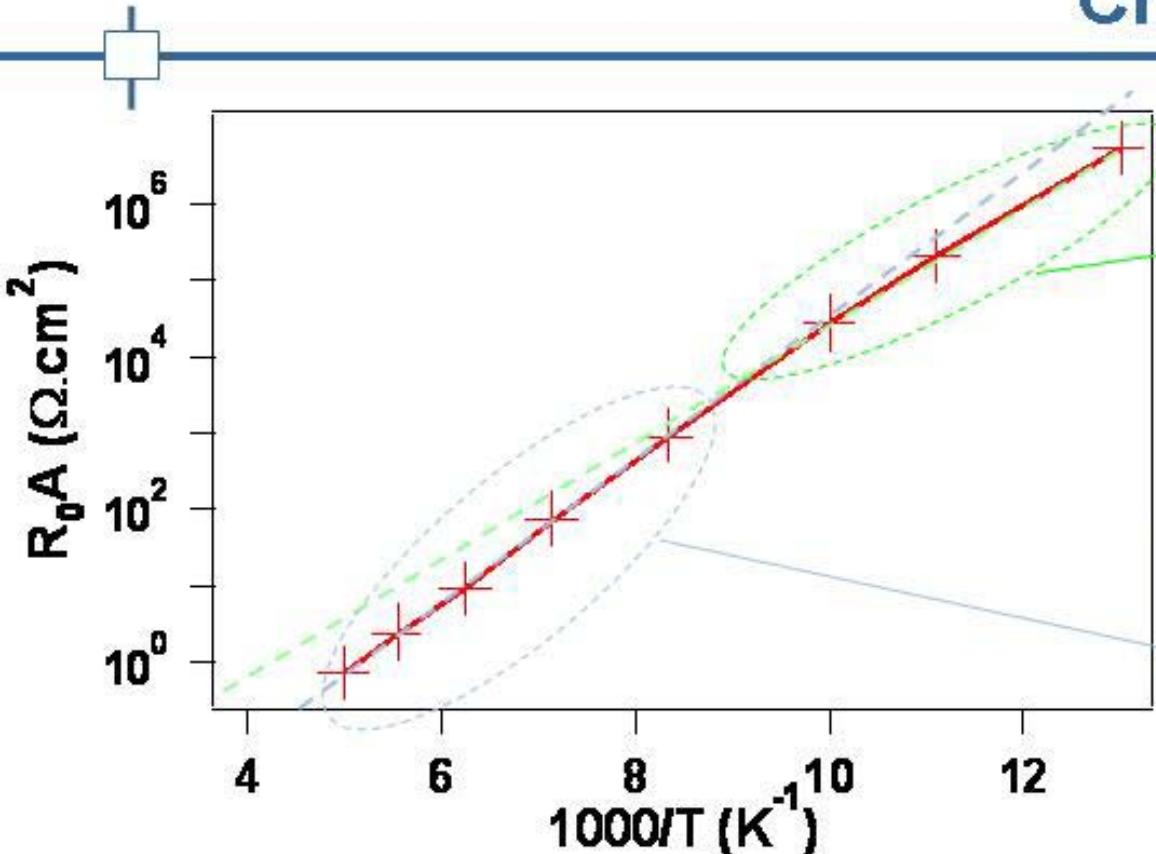


Responsivity at peak, for a $100\mu\text{m} \times 100\mu\text{m}$ pixel, at 120 K, at 0 V and with an optical coupling grating :

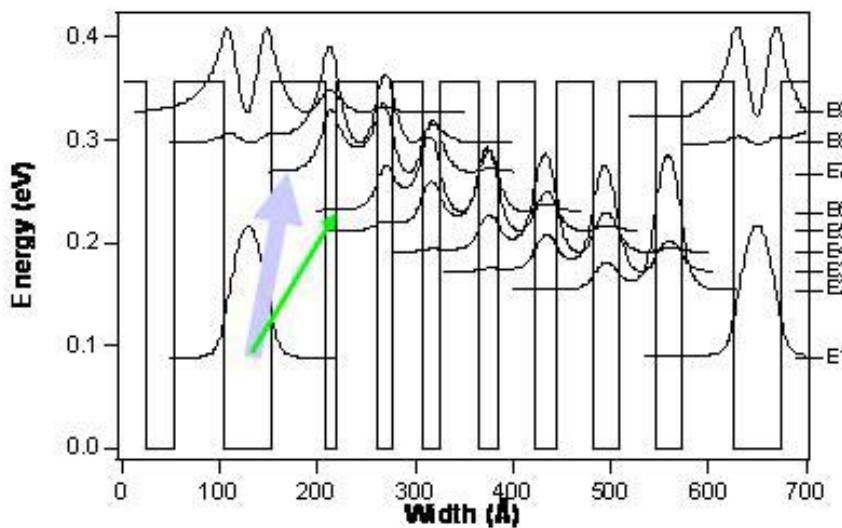
$$R = 15 \text{ mA/W}$$

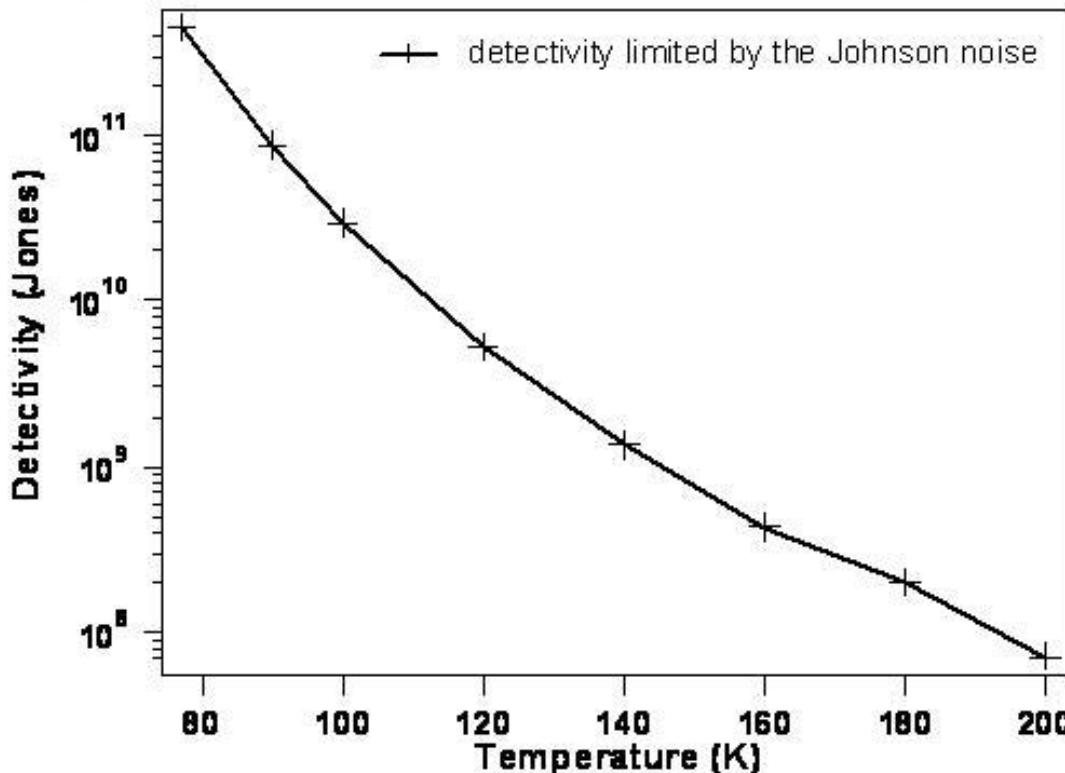
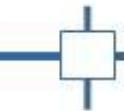


Characterization : resistivity



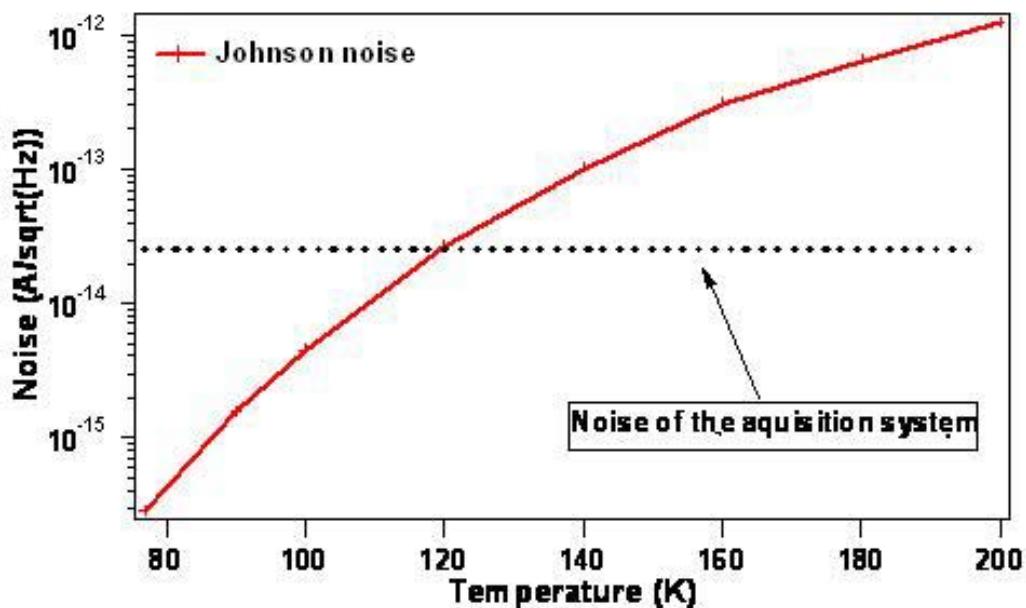
- High resistivity :
 - $5 \cdot 10^6 \Omega \cdot \text{cm}^2$ @ 77 K
 - $2.7 \cdot 10^4 \Omega \cdot \text{cm}^2$ @ 100 K
- leakage current due to transition toward a high energy level (E7)





- One order of magnitude lower than MCT
- Due to lower quantum efficiency
(same situation than QWIPS)

$D^* = 1.2 \times 10^9$ Jones
at 140 K, for a 100 μ m square mesa, with an optical coupling grating, at 0V



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- 1 \Rightarrow Electron/LO-phonons interaction = dominant scattering process
- 2 \Rightarrow The electronic mobility is higher inside a cascade than between two consecutive cascades
 - ➔ Intra and inter-cascade transitions classification
 - ➔ Introduction of quasi Fermi levels associated with each cascade
- 3 \Rightarrow Low applied bias (calculation of R_0A , and photovoltaic operation) : The electric field will be considered as a perturbation



1 \Rightarrow Predominant scattering process : Electron/LO-phonons interaction

Neglected scattering mechanisms :

- Interface roughness scattering
- Acoustic phonons scattering
- Electron-electron interactions

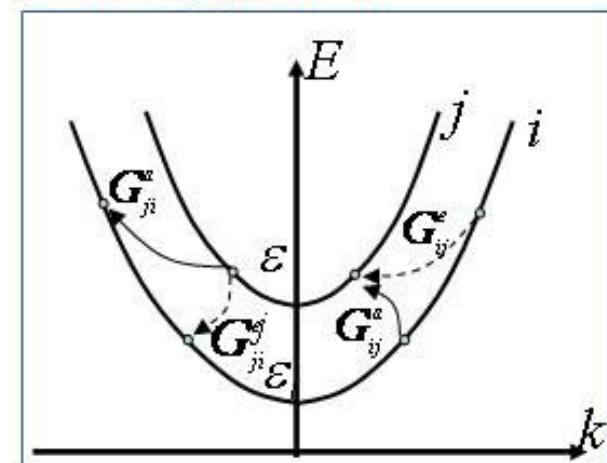
May not be true at very low temperature (see Leuliet et al. Phys. Rev. B 2006)

- not a problem for infrared detection application

$$G_{ij}^a = \int_{\epsilon_j - \hbar\omega_{LO}}^{\infty} S_{ij}^a(E) f(E) (1 - f(E + \hbar\omega_{LO})) n_{opt} D(E) dE$$

$$G_{ij}^e = \int_{\epsilon_j + \hbar\omega_{LO}}^{\infty} S_{ij}^e(E) f(E) (1 - f(E - \hbar\omega_{LO})) (1 + n_{opt}) D(E) dE$$

- S_{ij}^* single state transition rate to subband j
- G_{ij} global transition rate from subband i to subband j



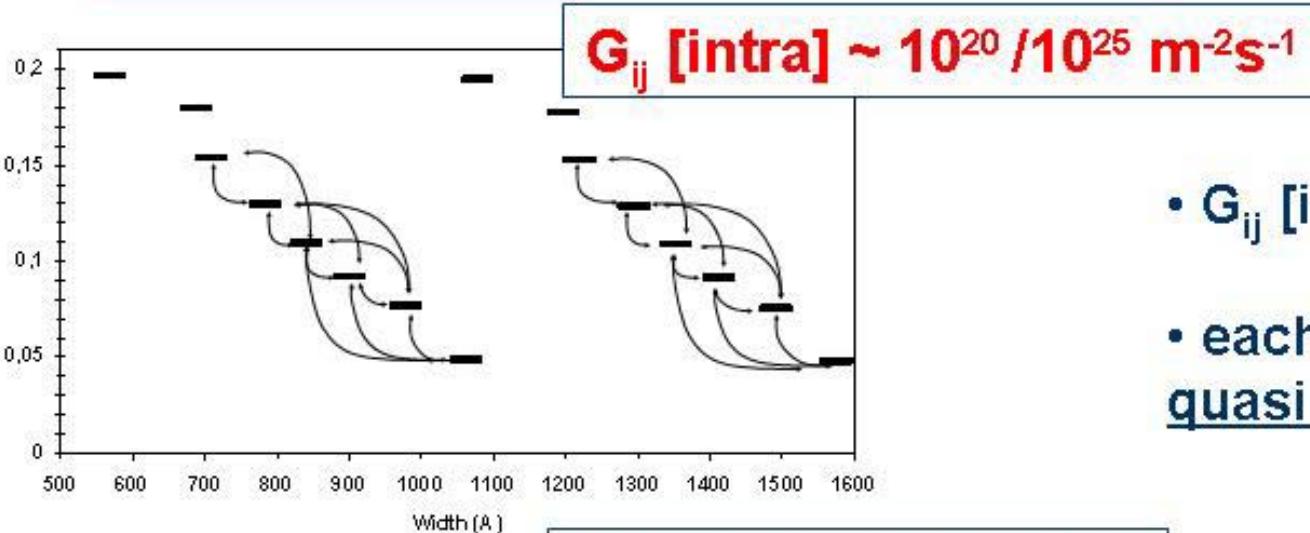
At thermodynamical equilibrium :

$$G_{ij}^a = G_{ji}^e$$

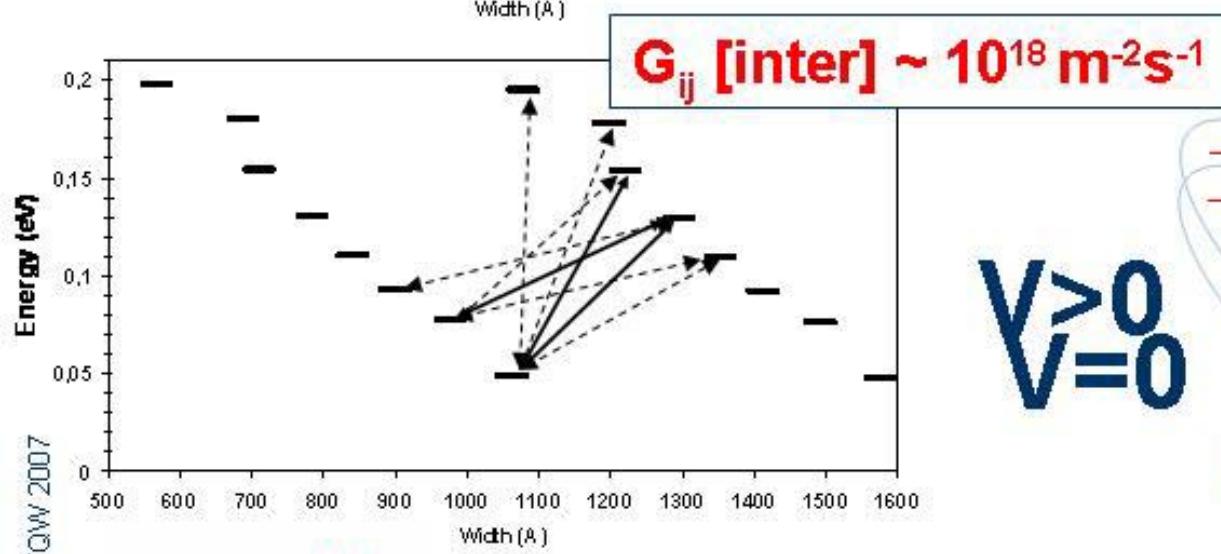
\Rightarrow The net current is zero



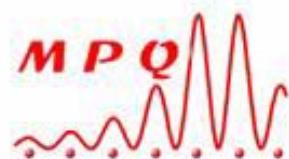
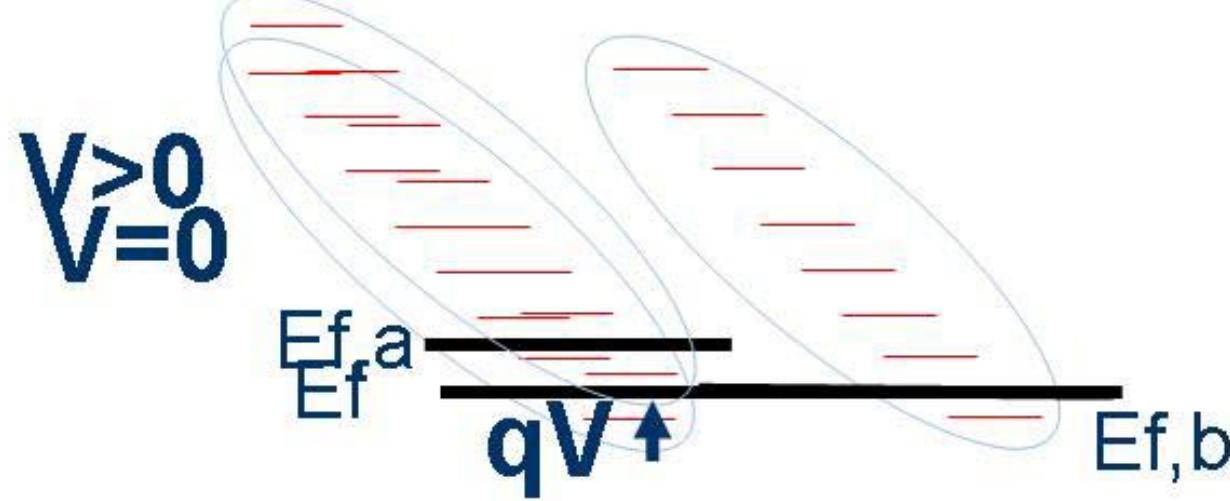
2 \Rightarrow Under bias, each cascade keeps its own quasi Fermi level



- $G_{ij} [\text{intra}] > G_{ij} [\text{inter}]$
- each cascade at quasi thermodynamical equilibrium



$$V > 0$$





⇒ 3 - The bias considered as a perturbation

$$G_{ij}^a(V) = \int_{\epsilon_j - \hbar\omega_{LO}}^{\infty} S_{ij}^a(E) f_A(E) (1 - f_B(E + \hbar\omega_{LO})) n_{opt} D(E) dE$$

The matrix elements do not depend on the very small applied bias

The bias breaks the Fermi level between subband i (cascade A) and subband j (cascade B)

These Fermi factors are different in G_{ij}^a and G_{ji}^e

$$G_{ij}^a \neq G_{ji}^e$$

A transport results from this non-equilibrium

$V > 0$

E_F

qV

$E_{F,b}$



$$J = q \sum_{i \in A} \sum_{j \in B} (G_{ij}(V) - G_{ji}(V)) = q \sum_{i \in A} \sum_{j \in B} G_{ij}^{\text{eq}} \frac{qV}{k_B T}$$

$$\Rightarrow R_0 A = \frac{k_B T}{q^2 \sum_{i \in A} \sum_{j \in B} G_{ij}^{\text{eq}}}$$

Einstein Relation

$$\frac{D}{\mu} = \frac{k_b T}{q} \quad \text{with} \quad D = \frac{l^2 \sum_{i \in A} \sum_{j \in B} G_{ij}^{\text{eq}}}{n_{2D}}$$

* C. Koeniguer et al., Phys. Rev. B,
74, 235325 (2006)





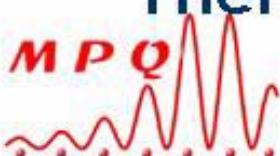
The resistivity depends only on :

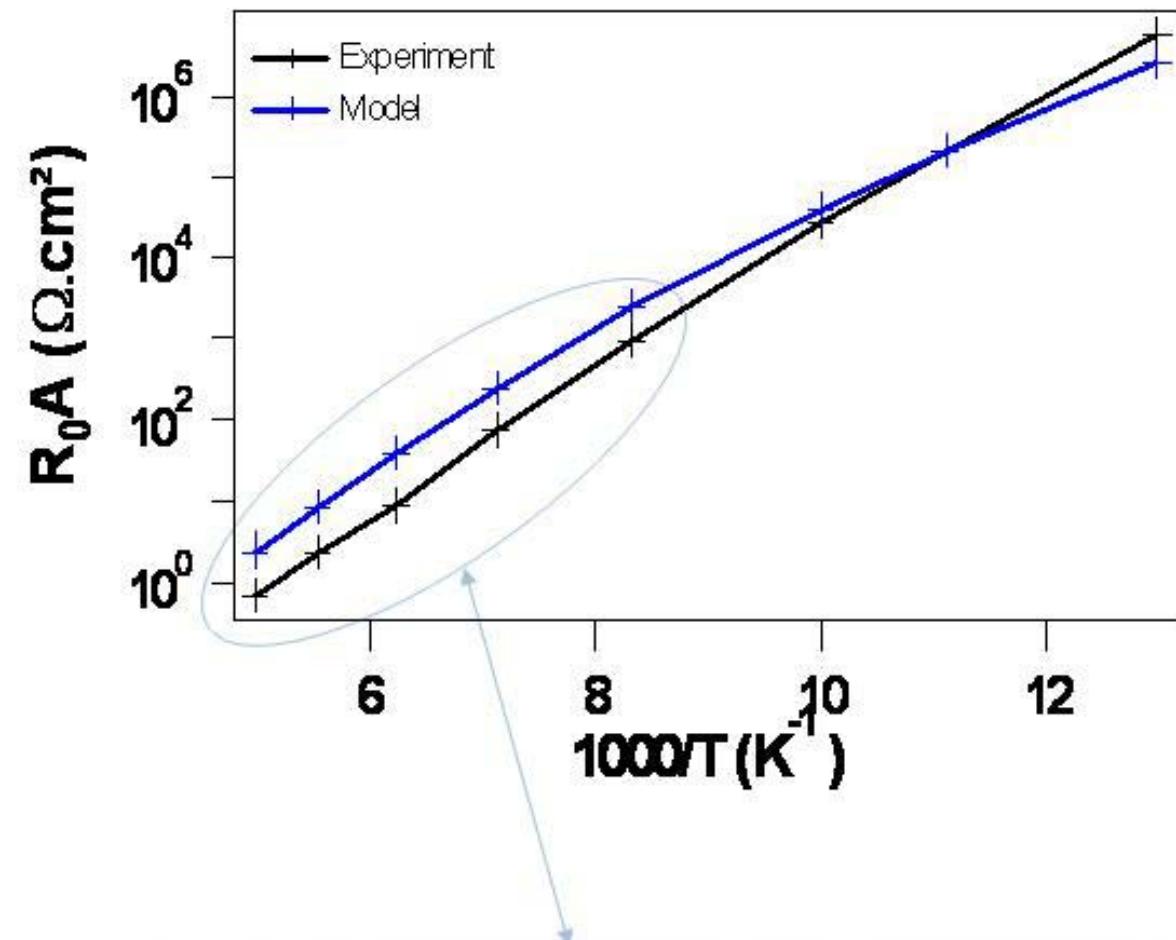
- the doping concentration
- the physical parameters of the sample (thickness of the wells and barriers, materials constants like effective masses or Al percentage ...)

which are included in the G_{ij} terms :

$$G_{ij}^a(v) = \int_{\varepsilon_j - \hbar\omega_{LO}}^{\infty} S_{ij}^a(E) f_A(E) (1 - f_B(E + \hbar\omega_{LO})) n_{opt} D(E) dE$$

There is no other adjustable parameters (no fit parameters)





- less than one order of magnitude
- The differences are due to :
 - the differences between the expected and the real structure
 - the hypotheses of the model concerning the scattering mechanism

But there is no fit parameters

At high temperature, activation energy is in good agreement with the experiment

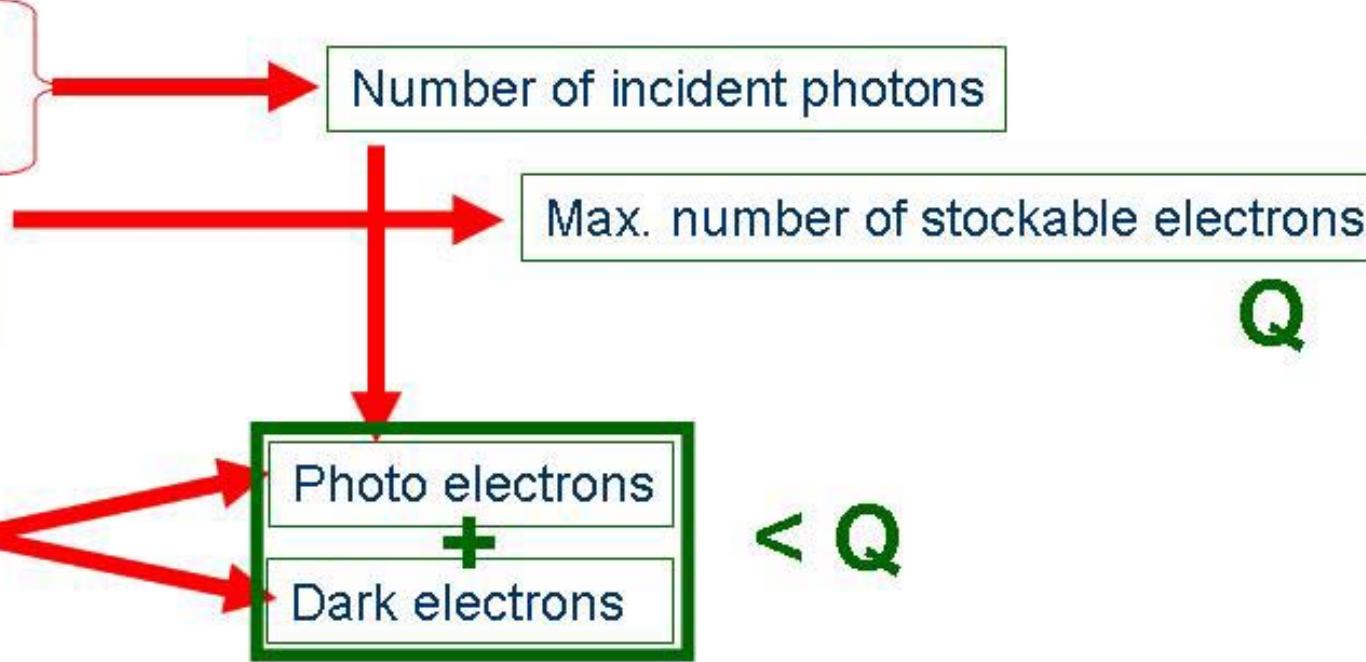




- True photovoltaic use
- Long integration times (no dark current)

The user

- Spectral band
- Working distance
- Integration time
- Pixel size
- Working temperature



The structure

- Doping level
- Applied bias (in a QWIP)
- Working temperature

This condition usually limits the doping level and/or the working temperature
 This has nothing to do with the detectivity

QCDs can work at higher doping levels than QWIPs : it may be interesting
 for low photon number application (4 μm, long distance...)





- Performances of a QCD at 5.7 μm :

- Responsivity at peak at 120 K : 15 mA/W
- High Resistivity : $5 \cdot 10^6 \Omega \cdot \text{cm}^2$ @ 77 K

- Model for electronic transport :

- No other adjustable parameters except the doping concentration and the constants of the materials
- Gives a good approximation of the resistivity
- This gives to the possibility of a calculation of the performances of the detector and the system during its design (as a function of number of wells, doping...)

Thank you for your attention.